



Version with markings to show changes made

Claim 1 (*Currently amended*): A process for removal of impurities from Nitric Oxide gas, for research, industrial, semiconductor, medical, and analytical application, comprising: (a) providing a ~~mixture~~ flow of impure Nitric Oxide ~~and its common impurities~~, (b) passing this gaseous mixture ~~trough~~ through a first filter composed by a mixture of hydroxides of alkali and earth alkali metals, (c) passing the mixture through a second filter system, (d) collecting the purified gas in a sealed delivery tank.

Claim 2 (*Currently amended*): The process for removal of impurities according to claim one, further comprising: maintaining the temperature of said first filter between 50 and 200 ~~298~~ degrees Kelvin.

Claim 3 (*Original*): The process for removal of light impurities according to claim 2, further comprising: maintaining a pressure between 0.1 and 1,000 atmospheres inside said delivery tank.

Claim 4 (*Original*): The process for removal of impurities according to claim 1, further comprising: retaining impurities in said first filter and in said second filter.

Claim 5 (*Currently amended*): The process for removal of impurities according to claim 1, wherein the impurities are selected from a group ~~comprising~~ consisting

of nitrogen dioxide (NO₂), sulfur dioxide (SO₂), methane (CH₄), oxygen (O₂), carbon monoxide (CO), carbon dioxide (CO₂), ozone (O₃), water (H₂O), ammonia (NH₃), nitrous oxide (N₂O) and volatile hydrocarbons.

Claim 6 (*Canceled*) The process for removal of impurities according to claim 1 where the mixture of hydroxides of alkali and earth alkali metal inside said filter 1 contains ASCARITE (registered trademark).

Claim 7 (*Original*): The process for removal of impurities from nitric oxide according to claim 1 where the mixture of hydroxides of alkali and earth alkali metals contains sodium hydroxide.

Claim 8 (*Currently amended*): The process for removal of impurities from nitric oxide according to claim 1 where the mixture of hydroxides of alkali and earth alkali metals ~~contains anyone~~ is selected by the group consisting of the following compounds: sodium hydroxide, barium hydroxide, calcium hydroxide, lithium hydroxide, magnesium hydroxide, potassium hydroxide, strontium hydroxide, cesium hydroxide, francium hydroxide, and silica hydroxide.

Claim 9 (*Original*): The process for nitric oxide purification according to claim 1, wherein said mixture of hydroxides of alkali and earth alkali metals is replaced upon depletion.

Claim 10 (Original): The process for nitric oxide purification according to claim 1, wherein said second filter contains a molecular sieve.

Claim 11 (Original): The process for nitric oxide purification according to claim 1, wherein said second filter is regenerated by flushing a dry gas and by heat.

Claim 12 (Original): The process for nitric oxide purification according to claim 1, wherein said nitric oxide conveyed to said delivery tank has a percentage of impurities between 0% and 1 %.

Claim 13 (Withdrawn): This claim was missing in the original application due to a typing error.

Claim 14 (Withdrawn): An apparatus for removing impurities from a nitric oxide mixture comprising: (a) a tank of impure nitric oxide, said tank having a first end and a second end; (b) a first inert tubing system connecting said first end to a first filter-pack, (c) a needle valve to regulate the gas flow through the filtering system, (d) a first filter-pack, (e) a second inert tubing system connecting said filter-pack to a second filter-pack, (f) a second filter-pack, (g) a third inert tubing system delivering the purified nitric oxide to a delivery tank, (h) a delivery tank.

Claim 15 (Withdrawn): The apparatus for removing impurities from a nitric oxide gas according to claim 14, further comprising: a refrigeration unit integral with or

separate from said first filter in order to maintain said first filter at a temperature between to and 298 degrees Kelvin.

Claim 16 (*Withdrawn*): The apparatus for removing impurities from a nitric oxide gas according to claim 14, comprising a vacuum pump.

Claim 17 (*Withdrawn*): The apparatus for removing impurities from a nitric oxide gas according to claim 14, wherein said second filter-pack is a molecular sieve.

Claim 18 (*Withdrawn*): The apparatus for nitric oxide purification, according to claim 14, wherein said first filter comprises silica dioxide supporting a hydroxide of an alkali or earth alkali metal.

Claim 19 (*Withdrawn*): The apparatus for removal of impurities according to claim 14, further comprising a tubing system internally coated with an inert material to avoid any reaction between the gas mixture and its internal surface. Said tubing system connecting all the elements of the apparatus.

Claim 20 (*Withdrawn*): An apparatus for filtering out impurities from nitric oxide comprising (a) a support of silica dioxide, (b) at least one hydroxide of alkali or earth alkali metals, (c) a box having inert interior surfaces and two openings, (d) a cooling system to cool down the temperature of the impure NO flow, (e) a metal filter-net to easy the deposition of the impurities.